

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4225	(BPSG or PSG or borophosphosilicate or phosphosilicate or silicate or glass) near20 (reflow\$6 or (re adj flow\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 12:34
L2	421196	SiO2 or SiO?sub\$2 or ((Si or silicon) adj (oxide or dioxide)) OR USG	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 12:35
L3	2555	1 and 2 and (semiconductor or IC or (integrated adj circuit))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 12:35
L4	1420	3 and (@ad<"19980203" or @rlad<"19980203")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 12:36
L5	325	4 and (SiN or Si3N4 or Si?sub??N?sub\$3 or (Si?sub\$3 adj N?sub\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 14:04
L6	827	4 and ((Si or silicon) adj nitride)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 14:05
L7	602	6 not 5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 14:05

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L5	325	4 and (SiN or Si3N4 or Si?sub??N?sub\$3 or (Si?sub\$3 adj N?sub\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/15 12:38